

# The EVEREST Doping Profile Module: Version 4

J V Ashby R F Fowler and C Greenough



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# The EVEREST Doping Profile Module: Version 4

### JV Ashby, RF Fowler and C Greenough

#### December 1998

#### **Abstract**

In this report we describe the EVEREST Doping Module which forms part of the EVEREST suite of programs.

The doping module is responsible for generating a neutral file which gives the acceptor and donor densities at each node the device mesh. The neutral file also contains details of the functions used to generate the doping as mesh refinement in the solver requires this. Commands allow the definition of background doping, regions of uniform doping, non-uniform doping relating to windows found in the Geometry neutral file and a user-programmable FORTRAN subroutine which computes doping concentrations as a function of position.

The EVEREST suite is one of the products of the ESPRIT project EVEREST (ESPRIT 962E-17, Three-Dimensional Algorithms for a Robust and Efficient Semiconductor Simulator with Parameter Extraction). EVEREST was a four-year project supported by the European Community under the European Strategic Program for Research in Information Technology (ESPRIT) which is investigating suitable algorithms for the analysis of semiconductor devices in three dimensions, and developing software implementing the most effective of those algorithms.

The original authors of the Doping Module were G.A. Duffett and M.S. Towers of University College, Swansea.

A copy of this report can be found at the Department's web site (http://www.dci.clrc.ac.uk/) under page Group.asp?DCICSEMSW or anonymous ftp server www.inf.rl.ac.uk under the directory pub/mathsoft/publications

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## **Contents**

1	intro	Oduction	1
2	User	Interface	1
3	Reco	ommended Procedure for Using the Doping Module	3
	3.1	Specifying input and output files	4
	3.2	Background and Uniform Doping	4
	3.3	Process and Profile simulations	4
	3.4	User provided functions	6
	3.5	Specification Validation	6
	3.6	Profile generation	7
	3.7	Program termination	7
4	Algo	rithms	7
5		nples Session	0
	5.1	A One-Sided <i>n-p</i> Step Junction	8
	5.2	A P-Channel Double-Diffused MOSFET	8
	5.3	Combined user defined profiles	8 9
	Tookas		9
A	Inter	mal Commands	11
	A.1	MORE - to display the contents a file	13
	A.2	CHANGE - to change working directory	13
	A.3	RENAME - to rename a file	13
	A.4	COPY - to copy a file	14
	A.5	RM - to delete (remove) a file	14
	A.6	LIST - to provide directory listing	14
	A.7	WRITE - to provide monitoring of a session	15
	A.8	READ - to specify a command input file	15
	A.9	SYNTAX - to provide the syntax of a command	16
	A.10	HELP - to access HELP system	17
В	Com	mand Reference Section	19
	B.1	BACKGROUND - to specify the uniformly doped background	21
	B.2	CUECV to list and about it	21
	B.3	ENITS to an Ada a succession	22
	B.4	FINCTION to appoin the same of	22
	B.5	GEOMETRY to provide the second in the	23
	B.6	PECAD to list volumes types and actual	23
	<b>B</b> .7	MECH to provide the seal date	24
	B.8	OUTDIT to specify the desire (section)	24 24
	B.9	DDOCECC to appoint a standard day're	2 <del>4</del> 24
	B.10	DDOEILE to appoint a year defendance 1 C1	2 <del>4</del> 26
	B.11	DIM to min the main meeting	20 27
	B.12	TITLE to appoint a 4/41- for all 11	21 20

B.13 UNIFORM - to specify a uniformly doped volume		28
--	--	----

### 1 Introduction

The doping module is responsible for generating a neutral file which gives the acceptor and donor densities at each node the device mesh. The neutral file also contains details of the functions used to generate the doping as mesh refinement in the solver requires this. Commands are used to set up a data base for the doping profile of the device. When everything is correctly set up the commands are executed creating the doping profile for the device. This information is then written to the Doping neutral file. The doping profile is computed by summing the contributions from the various parts of the doping definitions described by the user.

During the initial interactive set up phase for the data base, commands are provided for the input. The basic commands are:

TITLE - to specify a title for the problem

GEOMETRY - to specify input geometry neutral file

MESH - to specify input mesh neutral file

**RECAP** - to list the volumes and windows

BACKGROUND - to specify the uniformly doped background

UNIFORM - to specify a uniformly doped volume

PROCESS - to specify a doping process

PROFILE - to specify a doping profile

FUNCTION - to specify use of a user doping function

OUTPUT - to specify a doping neutral file

CHECK - to check and list the commands input

RUN - to begin execution of the program

END - to end program

The module is designed to be flexible so that entries can be checked and corrected at all stages before any calculations are made. Also, more than one neutral file may be generated in a single session by making the necessary changes to the data base of parameters before re-running. Some logic is included to prevent running of the doping calculations without a minimum of information being input. Essential items include specification of the Geometry and Mesh neutral files, and of the Output doping neutral file.

### 2 User Interface

The command decoder is initialised with all the syntax information for the command set of the module from a command file and then takes input from the terminal, or even a data file invoking individual commands, with their parameters. The modules use an interactive command decoder, developed at the Rutherford Appleton Laboratory, with an on-line help facility. This command environment allows you to input the doping information either interactively or by means of prepared data files which contain this data. The second mode of use is strongly recommended, especially if you are experimenting with doping levels.

The initial commands available to the user are given by the HELP command, as shown below. Full details of all the commands available in *doping* are given in the Appendixes.

### Model: Help

TITLE

### The commands currently defined are:

#### Applications Commands

to specify a title for the problem GEOMETRY - to specify input geometry neutral file MESH - to specify input mesh neutral file RECAP to list the volumes and windows BACKGROUND - to specify the uniformly doped background UNIFORM - to specify a uniformly doped volume PROCESS - to specify a doping process PROFILE to specify a doping profile - to specify use of a user doping function FUNCTION OUTPUT - to specify a doping neutral file - to check and list the commands input CHECK RUN - to begin execution of the program END - to end program

#### Internal Commands

MORE - to display the contents a file CHANGE - to change working directory RENAME to rename a file - to copy a file COPY ERASE - to delete (remove) a file LIST - to provide directory listing WRITE - to provide monitoring of a session READ - to redirect the input stream to read from a file SYNTAX - to provide the syntax of a command HELP - to access HELP system For further information type: HELP <command name> [<option>], where <option> is BRIEF or FULL

All the commands can be typed in upper or lower case. The syntax of each command can be obtained by using the syntax command. For example

```
Geometry: syntax write
WRIte STAte=<choice> [,FIle=<string>] [,PROmpt=<choice>]
Geometry:
```

To get full details on a command and its parameters, such as the WRITE command, you can use HELP WRITE.

Model: help write

: WRITE

Purpose : to provide monitoring of a session

Syntax : WRIte STAte=<choice> [,FIle=<string>] [,PROmpt=<choice>]

Keyword	Type	Status	Current Value
STATE FILE PROMPT	choice string choice	required retained reset	on,off,close MONITOR on,OFF

A command can be abbreviated, the shortest value being indicated by the uppercase letters in the syntax section, e.g. the Write command may be shortened to just wri. The system is reasonably simple to use and working through one or two of the examples below should enable one to get to grips with it.

Doping module provides a number of internal commands. These commands, such as HELP and COPY, provide standard information and file handling from within doping. As with all commands, details of their usage can be obtained through the HELP command. A summary of these commands is given in Appendix A.

Those commands that access the file store do so by invoking the appropriate system command of the operating system being used. This means that in general if an error report is produced it will be that of the host operating system.

For example, on UNIX systems, the RENAME command will use the UNIX command mv. Similarly LIST uses the UNIX command 1s. Although the parameter types for these commands is *string*, the appropriate host systems file expression and options can be used provide any expression that contains spaces is contained within quotation marks. An example of this is:

On a UNIX system this command will list all files with extension .MSH in the current working directory.

### 3 Recommended Procedure for Using the Doping Module

The doping generation module commands are relatively easy to use. However, you must know in detail which named volumes correspond to which uniform doping values and which windows correspond to which implantation parameters. This is complicated by the fact that one physical window may comprise several named windows in the geometry, all of which have to be specified individually.

The *doping* program allows you to build up an impurity distribution for the device you wish to simulate. This distribution is part of the physical data, which together with a description of the geometry and finite element mesh, are required for simulation.

Two types of distribution are permitted:

- Constant doping (usually epitaxial or bulk semiconductor layers)
- Non-uniform doping (for example, diffused p or n-type wells).

The doping density is always in units of  $cm^{-3}$ . All geometric lengths and standard deviations (diffusion lengths) must be given in *micron* units. The non-uniform distributions are formed by implanting impurities through a window in a mask on the semiconductor surface and then diffusing the impurities into the semiconductor.

### 3.1 Specifying input and output files

Doping reads two input files and generates a single output file. The input files are the standard geometry and mesh neutral files produced by the pre-processor. The commands GEOMETRY, MESH and OUTPUT are those used. A typical example is:

GEOMETRY PN.GEO MESH PN.MSH OUTPUT PN.DOP

### 3.2 Background and Uniform Doping

The underlying impurity type of the substrate can be specified using the BACKGROUND command. BACKGROUND should be used to specify the acceptor and donor background doping.

```
BACKGROUND ACC=1.0D18 DON=1.0D12
```

The UNIFORM command is very similar to BACKGROUND save that it only applies to specific volumes. To specify the acceptor and donor uniform doping in a named volume the command

```
UNIFORM VOL=V1 ACC=1.0D18 DON=1.0D12
```

could be used. If several volumes have the same dopings, these can be set in the same command by including the names in a list inside round brackets and separated by commas.

```
UNIFORM VOL=(V1, V2, V4) ACC=1.0D18 DON=1.0D12
```

If a volume is referred to more than once a warning is issued and the previous values overwritten. This feature allows you to edit the parameters before committal to what may be a long execution time when the RUN command is used.

### 3.3 Process and Profile simulations

The PROCESS or PROFILE commands are used to specify the doping parameters to be applied through a named window. The PROCESS command uses predefined functions to compute the vertical and lateral doping distributions, while the PROFILE command makes use of a user-defined vertical profile with a choice of a predefined lateral distributions.

The PROCESS command provides three standard processes:

- predeposition,
- drive-in diffusion
- ion implantation.

Each process is described by the user in terms of constants that are used in the defined lateral and vertical functions used to compute the doping distribution. Densities are all in units of  $cm^{-3}$  and geometric lengths and deviations (diffusion lengths) are in *micron* units.

For a predeposition process, the vertical profile is computed using a complementary error function, and the lateral profile using a rotated ellipse. The drive-in diffusion profile is computed using a vertical Gaussian distribution with a rotated ellipse lateral profile. The ion implantation profile is computed using a vertical Gaussian distribution but with the peak below the surface; the lateral profile is computed using a complementary error function.

The windows through which the implant are made must be rectangular, although more complex shaped windows can be made up as a series of abutting rectangles.

An example of the PROCESS command is:

```
PROCESS TYPE=PREDEPOSITION, CONSTANTS=(2.6D18,3.D0,0.5), DOPTYPE=ACCEPTOR, WINDOW=WINDOW3, ACTION=ADD
```

which applies a predeposition of acceptor through a window WINDOW3.

The PROFILE command enables a user-defined vertical doping profile to be used in the computation of the doping distribution. The depths and concentrations of the one dimensional vertical profile are obtained from the neutral file which is named in the command. Concentrations must have units of  $cm^{-3}$  and depths must have *micron* units. The extension .PRO must not be included in the parameter. There is a choice of using either a rotated ellipse or a complementary error function to describe the lateral distribution. The lateral standard deviation constant, used with the complementary error function, must have *micron* units. No doping concentrations are computed outside the range of depths given in this vertical profile.

An example of the PROFILE command is:

```
PROFILE FILE=vertic, LATYPE=rotate, CONSTANT=0.5,
DOPTPE=ACCEPTOR, WINDOW=wndw3, ACTION=ADD
```

An example of the contents of a profile file is given below:

```
$HEAD
VER_03_87
$CASE
 Profile data on channel
$PROF
-1.000000E-04 2.9899778E+16
1.5779767E-02 3.0109827E+16
 4.2018358E-02 3.0482244E+16
 6.3974053E-02 3.1023148E+16
9.2864849E-02 3.2090907E+16
 0.1274796 3.3449031E+16
 0.1584477
            3.4070101E+16
 0.1962833
             3.3943749E+16
 0.2271500
             3.3510052E+16
0.2646408
            3.2311666E+16
 0.3134241
            3.1011025E+16
 0.3559420
            2.9788237E+16
0.3978915
              2.9021569E+16
0.4290017
            2.8692063E+16
 0.4676223
              2.8385366E+16
0.4969734
              2.8098602E+16
0.5405805
              2.7929309E+16
              2.7743608E+16
0.5929564
0.6290532
              2.7558050E+16
0.6673896
              2.7457054E+16
0.7120115
              2.7216817E+16
 0.7403207
              2.7169882E+16
```

```
1.5000000 2.7117668E+16
$END-PROF
$END-CASE
$END-HEAD
```

It should be noted that this is a fixed format file in the style of the general neutral files.

In both the PROCESS and PROFILE commands if several windows have the same parameters, these can be set in the same command by including the names in a list. If the ACTION parameter is REPLACE then the parameters of the last occurrence of that window are replaced. This feature allows the last entry to be corrected. If the ACTION parameter is ADD then a new entry is made to the data structure, allowing multiple implants to be made through the same window.

If several named windows make up one physical window then the parameters will only be updated if the newly input physical window corresponds with that already present in the data structure. The one restriction on the windows is that all named window must be rectangular. A physical window can thus be of any shape provided that its component named windows are all rectangular. If a window is referred to more than once a warning is issued.

### 3.4 User provided functions

If a user-programmed subroutine is to be used to compute additional impurity contributions the command FUNCTION must be used to indicate this to the controlling program. It is the responsibility of the user to ensure that no errors are present in this routine (called DOPEFN) and that the routine is correctly compiled and linked into the controlling main program. The Solver Module also requires any new doping functions linked into it.

#### 3.5 Specification Validation

You are strongly recommended to use the CHECK command to confirm the correctness and completeness of the parameters set. The commands used and not used are listed, together with tables for background, uniform and non-uniform doping. The input files (geometry and mesh) and the output file (doping) are also displayed.

An example of the output from CHECK is given below.

```
Dope: CHECK
  Geometry filename is CORNER.GEO
  Mesh
          filename is CORNER.MSH
  Output
          filename is CORNER.DOP
  The following COMMANDS have been used :
  *** No Title has been set ***
  BACKGROUND DOPING :
                        A ==
                                0.
                                      D = 0.150E + 18
  *** No Uniform doping has been set ***
  NON-UNIFORM DOPING, number of doping windows =
  PROCESS/PROFILE commands used
                                  2 times
```

```
PROCESS command :
Window Process Dopant Constants
W1
        Ion impl Acc 0.1000E+19 0.1445E+01 0.1445E+01 0.0000E+00
W2
                       0.1000E+19 0.1445E+01 0.1445E+01 0.0000E+00
        Ion impl Acc
W3
                       0.1000E+19 0.1445E+01 0.1445E+01 0.0000E+00
        Ion impl
                 Acc
W1
        Ion impl Acc
                       0.1000E+18 0.1200E+01 0.7850E+01 0.0000E+00
W2
        Ion impl
                       0.1000E+18 0.1200E+01 0.7850E+01 0.0000E+00
                 Acc
W3
        Ion impl
                 Acc
                        0.1000E+18 0.1200E+01 0.7850E+01 0.0000E+00
```

\*\*\* No PROFILE command used \*\*\*

The RUN command will not execute unless the CHECK command has been used at least once in the current session.

### 3.6 Profile generation

When all the parameters have been satisfactorily specified the RUN command is invoked. Only at this stage are the possibly lengthy calculations commenced and, if all goes well, the results will be written to the output doping neutral file. Control returns to the command decoder so that, at this stage, further neutral files can be created without ending and re-running the program. It may only be necessary to make minimal changes in the data base of the parameters. If a new geometry file is specified, however, the uniform and non-uniform doping data structures will be erased.

### 3.7 Program termination

When the task is finished the module is exited with the END command. This cannot normally take place if the RUN command has not been used. The action can be forced, however, by use of the CONFIRM parameter, set to Y.

### 4 Algorithms

All the commands, except RUN and END, either set up the doping data structures, read input from the terminal or a data file, or list information to the terminal for reference and checking purposes. A system of flags is used to cause reminders to be given if you have not set certain parameters, and also to prevent execution failures if the run command is invoked before essential filenames are supplied. As much information as possible, which is independent of the mesh nodes, is computed and stored when setting up the data structures. This allows the main doping calculations to proceed as efficiently as possible.

Inside the main loop over the mesh nodes, each node is taken in turn. Initially acceptor and donor doping are zero. Then, if set, background doping is added in. Next, if uniform doping is set, the volumes containing the node are identified. To ensure that interface nodes are included in all the relevant volumes, tolerances are added to the volume dimensions This expands them slightly so that such nodes will lie inside them all. Amongst the various uniform doping values available, the interface node is assigned the most significant acceptor/donor pair, according to the following rule:

If the current values of acceptor and donor concentration exceed both the new uniformplus-background values then the current values are retained; otherwise the new values for donor and acceptor concentration are kept. Next each contribution is added in from the doped windows. In the present implementation there are three predefined doping distributions corresponding to the following doping processes:

- predeposition,
- drive-in diffusion,
- ion implantation.

Each of these processes uses the parameters supplied through the PROCESS command.

Often windows are to be built up using several panes. This can arise when a non-rectangular window is required and the procedure is to dissect the shape into adjacent rectangular components. Also the need can arise when a physical window spans more than one volume. Since the geometric description restricts windows to lie entirely within a given surface, these types must be decomposed into segments unique to each surface coincident with the original window. The geometric representation does not distinguish between a window and a window pane, and consequently the difference is communicated to the doping module by ensuring that all panes of the same window are included in a list when the appropriate command is used. Windows containing common edges are put into groups so that the non-common window edges become the boundaries of the physical window. When computing the doping at a node, the nodal position with respect to the physical window is determined (i.e. inside the window, external to a boundary or external to a corner) and hence the correct doping for that position can be found.

Finally, the doping contributions computed by the user-programmed routine as a function of nodal co-ordinates are included into the total impurity profile.

### 5 Examples Session

### 5.1 A One-Sided n-p Step Junction

This doping definition can be used with the example given in the GEOMETRY program.

```
GEOM NP
MESH INI
RECAP
UNIF N+SI, 3.0D14, 1.0D19
UNIF P_SI, 5.0D15, 1.0D14
OUT NP
CHECK
RUN
END
```

### 5.2 A P-Channel Double-Diffused MOSFET

```
geo file=DMOS
mesh file=DMOS
uniform vol=v1, a=3.0D15, d=2.5D12
process predep cons=(2.6D18,3.0,0.5) doptype=d wind=nimpl
process drive cons=(1.0D19,6.0,0.75) a (pimplant,window2)
CHECK
```

```
OUTPUT FILE=DMOS
RUN
END
```

# 5.3 Combined user defined profiles

```
geom NP
mesh file=ini
output FILE=NP
check
profile myfile rot 0.5 acc (window1,window2)
FUNCTION
run
END
```

### **A** Internal Commands

<b>A</b> .1	MORE	to display the contents a file
A.2	CHANGE	to change working directory
A.3	RENAME	to rename a file
A.4	COPY	to copy a file
A.5	RM	to delete (remove) a file
A.6	LIST	to provide directory listing
A.7	WRITE	to provide monitoring of a session
A.8	READ	to redirect the input stream to read from a file
A.9	SYNTAX	to provide the syntax of a command
A.10	HELP	to access HELP system

### A.1 MORE - to display the contents a file

### **Syntax**

MORe FILe=<string>

### **Description**

Displays the contents of the specified file in the current window.

#### **Parameters**

**FILE** 

Required string

A string giving the name of the file to be displayed.

### **Examples**

more file=ANODE
MOR CATHODE

### A.2 CHANGE - to change working directory

### **Syntax**

CHAnge DIRectory=<string>

### Description

Changes the current working directory.

#### **Parameters**

DIRECTORY

Required string

A string giving the name of the new working directory.

### **Examples**

change directory=results CHA MODELS

### A.3 RENAME - to rename a file

#### **Syntax**

REName FILe1=<string> FILe2=<string>

### Description

Renames a given file to a new name.

### **Parameters**

FILE1

Required string

A string giving the current file name.

FILE2

Required string

A string giving the new file name.

### **Examples**

RENAME FILE1=RESULT1 FILE2=RESULT.SAVE ren output1 output2

### A.4 COPY - to copy a file

### **Syntax**

```
COPy FILe1=<string> FILe2=<string>
```

### **Description**

Copies a given file to a new file.

#### **Parameters**

FILE1

Required string

A string giving the source file name.

FILE2

Required string

A string giving the destination file name.

### **Examples**

```
COPY FILE1=RESULT1 FILE2=RESULT.SAVE cop output1 output2
```

### A.5 RM - to delete (remove) a file

### **Syntax**

```
RM FILe=<string>
```

### **Description**

Removes (deletes) the given file from the file system.

### **Parameters**

FILE

Required string

A string giving the name of the file to be removed (deleted).

### **Examples**

```
RM FILE=RESULT rm output
```

### A.6 LIST - to provide directory listing

### **Syntax**

```
LISt [FILe=<string>]
```

### **Description**

Provide a listing of the current or specified directory.

### **Parameters**

FILE

Optional string: initial = " "

A string giving the name of the file.

### **Examples**

LIST

lis \*.MSH

### A.7 WRITE - to provide monitoring of a session

### **Syntax**

### **Description**

Redirects the command decoder echo output to the file specified by the FILE parameter. The information flow is controlled by the STATE parameter. This command can enable the constructions of command files to drive the program in a background mode.

The echoing of the command prompt can be controlled using the PROMPT parameter.

### **Parameters**

STATE required choice

Controls the flow of information to the monitoring file It has values NO, OFF or CLOSE. ON switches on monitoring. OFF suspends it but does not close the file and CLOSE ends moni-

toring and closes the file.

FILE retained string: initial = MONITOR

Output file name to receive the monitoring stream.

PROMPT reset *choice*: initial = OFF

Allows you to select whether the command prompt is echoed

in the monitoring file. It has values ON or OFF.

### **Examples**

```
WRITE STATE=ON FILE=MONITOR PROMPT=OFF wri on junk on
```

### A.8 READ - to specify a command input file

#### **Syntax**

```
REad FIle=<string> [ECHO=<choice>]
```

### Description

Redirects the command decoder to take its input from a file specified by the FILE parameter. However, if FILE is given as TERMINAL, input returns to the standard input stream.

The echoing of the commands being read by the decoder can be controlled using the ECHO parameter.

#### **Parameters**

FILE

required string

Input file name containing program commands.

**ECHO** 

reset choice: initial = OFF

Echo control option. Values can be ON or OFF.

### **Examples**

In this example a sequence of commands are read from the file NAIL and ECHOed to the standard output device:

Everest: read nail echo=on

Everest: GEO \* >DATA>NAIL.GEO

Everest: MES \* >DATA>OXNAIL.MSH

Everest: DOP \* >DATA>NAIL.DOP

Everest: RES NAIL.OUT R

Everest: PHY NAIL.PHY
Everest: BIAS LEFT-CNT 0

Everest:

### A.9 SYNTAX - to provide the syntax of a command

### **Syntax**

```
SYNtax [COMmand=<string>]
```

### Description

Displays the formal syntax of all the currently defined commands. If the syntax of a specific command name is required then that name is given as a parameter to the command.

#### **Parameters**

**COMMAND** 

retained string: initial = ALL

Specifies the commands name for which the syntax is required. If the syntax of all the currently defined commands is required,

then the special command name ALL should be used.

### **Examples**

The following example obtains the syntax of all the commands in the DOCUMENT program.

```
Doc: syntax

The commands currently defined are:

SYNtax [COMmand=<string>]

Help [KEY=<string>] [OPTion=<string>]
```

### A.10 HELP - to access HELP system

### **Syntax**

```
Help [KEY=<string>] [OPTion=<choice>]
```

### Description

Accesses to the inbuilt HELP system within the command decoder. HELP is one of the internal commands of the command processor and has a companion command SYNTAX.

HELP has two parameters allowing the selection of help on a specific command and the level of help required (SUMMARY, BRIEF, FULL and SYNTAX). If no command name is given summary help is given on all the commands currently defined.

If an ambiguous or invalid command name is given a warning or error message is given.

BRIEF help gives information on the purpose, syntax and the current state of the selected command. A table of command keywords, their type, status and current value (if applicable) is printed.

When the FULL option is used the Help System uses the inbuilt free text retrieval system to access the help data base. This allows the display of the full command description and the searching for specific keywords. This option is not supported in the current release.

#### **Parameters**

KEY

reset string: initial =

Either the global command name SUMMARY, or the specific

command name on which help is sought.

**OPTION** 

reset *choice*: initial = BRIEF

The level of help required. This can be SUMMARY, BRIEF,

FULL or SYNTAX.

### **Examples**

Everest: help output

Name : OUTPUT

Purpose : to specify results file

Syntax : OUTput FILE=<string> [REPLACE=<choice>]

Keyword	Туре	Status	Current Value
FILE	string	required	undefined
REPLACE	choice	reset	replace,NOREPLACE

# **B** Command Reference Section

B.1	BACKGROUND	to specify the uniformly doped background
B.2	CHECK	to list and check the commands already typed
B.3	END	to end the program
<b>B</b> .4	FUNCTION	to specify the use of a user doping function
B.5	GEOMETRY	to provide the geometric data
B.6	RECAP	to list volumes and windows
B.7	MESH	to provide the mesh data
<b>B.8</b>	OUTPUT	to specify the doping (output) neutral file
<b>B.9</b>	PROCESS	to specify a standard doping process
B.10	PROFILE	to specify a user-defined vertical profile
B.11	RUN	to run the main routine
B.12	TITLE	to specify a title for the problem
B.13	UNIFORM	to specify a uniformly doped volume
		· • •

### B.1 BACKGROUND - to specify the uniformly doped background

### **Syntax**

```
BACKground Acceptor=<real> Donor=<real>
```

### **Description**

Specifies the acceptor and donor densities of the uniformly doped background region. This command is used to avoid having to type in the same doping values for many volumes.

#### **Parameters**

ACCEPTOR required real in  $cm^{-3}$ : always positive

Typical values are in the range  $1 \times 10^{14}$  to  $1 \times 10^{19} cm^{-3}$ .

DONOR required real in  $cm^{-3}$ : always positive

Typical values are in the range  $1 \times 10^{14}$  to  $1 \times 10^{19} cm^{-3}$ .

### **Examples**

```
BACK A=1.0D18, D=1.0D12
back 1.0D12, 1.6D14
```

### B.2 CHECK - to list and check the commands already typed

#### **Syntax**

CHECK

### Description

Lists the commands input so far. If the number of specified volumes exceeds the number of UNIFORM commands when the BACKGROUND command has not been used, it indicates which volumes have not had doping values assigned to them. If the geometry file, mesh or output file has not been specified, it issues a warning to this effect. It can be used at any stage before the RUN command to verify commands and parameters already typed in. It is recommended that this command is used at least once before running the main routine with the RUN command.

#### **Parameters**

This command has no parameters.

#### **Examples**

CHECK

### B.3 END - to end the program

### **Syntax**

```
END [Confirm=<choice>]
```

### Description

Halts the program. Normally this cannot happen if the RUN command has not been used. If you really want to exit, this can be forced by setting the Confirm parameter to Y.

#### **Parameters**

Confirm

an optional choice: initial = NO

Confirmation of ending. Values are (Yes, No).

### **Examples**

END

END Y

### B.4 FUNCTION - to specify the use of a user doping function

### **Syntax**

FUNCtion NUmber=<integer>

### **Description**

A number of different doping functions can be selected by the use of the integer value NUMBER. This value is passed to the the embedded routine DOPEFN. Specifies the use of a user-defined (and programmed) routine called via DOPEFN which is used to compute doping contributions as a function of the position co-ordinates (x, y, z). The user may add any FORTRAN coding to the routine DOPEFN in order to compute doping contributions at the nodes in the geometry of the device being modelled. Real-valued functions must however, be provided for both the acceptor and the donor densities (units of  $cm^{-3}$ ). It must be noted that since the doping is computed node by node this routine must provide a doping contribution for *every* node in the mesh. Obviously these nodal contributions can be set to zero in certain regions of the device as required. Further details can be found in the preamble to the routine DOPEFN.

Note that changes to DOPEFN must also be include in the Solver Module.

The user must ensure that no errors exist in the routine and that it is properly compiled and linked into the main program (see local user instructions for details).

#### **Parameters**

**NUMBER** 

required integer

A integer value specifying the which of the available doping

functions should be used..

### **Examples**

```
FUNCTION 1 func 2
```

### B.5 GEOMETRY - to provide the geometric data

### **Syntax**

```
GEOmetry FILE=<string>
```

### Description

Specifies the neutral file from which the geometry information is to be taken. The information will be read using the neutral file reading routines. The extension .GEO must not be included in the parameter and it must not exceed 20 characters in length.

#### **Parameters**

**FILE** 

required string

A string value specifying the neutral file name.

### **Examples**

```
GEO FILE=PN geo mos
```

### B.6 RECAP - to list volumes types and windows

### **Syntax**

RECap

### Description

Lists the volumes and windows that have been defined in the geometry neutral file. One UNIFORM command is expected to be input for each volume unless the BACKGROUND command has been used. There may be more windows than implant-diffusion steps as the contacts can be specified as windows.

### **Parameters**

This command has no parameters.

### **Examples**

RECAP

### B.7 MESH - to provide the mesh data

### **Syntax**

```
MESh FILE=<string>
```

### Description

Specifies the neutral file from which the mesh information is to be taken. The information will be read using the neutral file reading routines. The extension .MSH must not be included in the parameter and it must not exceed 20 characters in length.

#### **Parameters**

**FILE** 

required string

A string value specifying the neutral file name.

### **Examples**

```
MES FILE=FINE mesh ini
```

### B.8 OUTPUT - to specify the doping (output) neutral file

### **Syntax**

```
OUTput FILE=<string>
```

### Description

Specifies the neutral file to which the nodal values of the acceptor and donor concentrations will be output. The extension .DOP must not be included in the parameter and it must not exceed 20 characters in length. The information will be written using the neutral file writing routines. This command must be used before the RUN command.

#### **Parameters**

FILE

required string

A string value specifying the neutral file name.

### **Examples**

```
OUTPUT FILE=PN output mos
```

### B.9 PROCESS - to specify a standard doping process

#### **Syntax**

```
PROCess TYPe=<choice> CONstants=<rlist> DOPtype=<choice> WINdow=<slist> [ACTion=<choice>]
```

### Description

Specifies a standard doping process and the names of the windows for this doping. There are three standard processes:

- predeposition,
- drive-in diffusion
- ion implantation.

Each process is described by the user in terms of constants that are used in the defined lateral and vertical functions used to compute the doping distribution. Densities are all in units of  $cm^{-3}$  and geometric lengths and deviations (diffusion lengths) are in *micron* units.

For a predeposition process, the vertical profile is computed using a complementary error function, and the lateral profile using a rotated ellipse. The drive-in diffusion profile is computed using a vertical Gaussian distribution with a rotated ellipse lateral profile. The ion implantation profile is computed using a vertical Gaussian distribution but with the peak below the surface; the lateral profile is computed using a complementary error function.

Windows must be rectangular. Odd shaped windows can be made up as a series of abutting rectangles and must be included in the same string list when the command is used.

It is recommended that no more than three implants share a common window. This is to avoid errors in the calculation of the impurity distribution since the solution assumes non-interacting impurities.

### **Parameters**

TYPE required string

A string which gives the name of the process required values

are (PREdeposition, DRIvein, IONimplantation).

CONSTANTS required reallist

A list of positive constants required for the computation of the doping profile. The number and meanings of the constants are different for each of the processes. The constants required are:

(1) predeposition (3 constants):

 $N_0$  - solid solubility limit at the surface

 $\sigma_A$  - diffusion length =  $\sqrt{Dt}$ 

 $\alpha$  - parameter describing ellipse

(2) drive-in diffusion (3 constants):

 $N_t$  - total impurity per unit surface area

 $\sigma_A$  - diffusion length =  $\sqrt{Dt}$ 

 $\alpha$  - parameter describing ellipse

(3) ion implantation (4 constants):

 $N_p$  - peak impurity concentration (when  $\sigma_B = 0$ )

 $x_p$  - depth of peak below surface  $\sigma_A$  - vertical standard deviation  $\sigma_B$  - lateral standard deviation

DOPTYPE

required choice

The type of doping. Values are (Acceptor, Donor).

**WINDOW** 

required stringlist

The list of window names for which this doping is applied.

**ACTION** 

optional choice: initial = ADD

The ACTion, if a window has already been doped is either Add

or Replace. Values are (Add, Replace)

### **Examples**

```
PROC TYP=pred, CON=(2.6D18,3.D0,0.5), DOPT=a, WIND=(wndw3,wndw4) proc ION (2.D16,1.2D0,3.,2.) a (w1,w2,we14,w5) add
```

### B.10 PROFILE - to specify a user-defined vertical profile

### Syntax

```
PROFile FILe=<string> LAType=,choice> CONstant=<real> DOPtpe=<choice> WINdow=<slist> [ACTion=<choice>]
```

#### Description

This enables a user-defined vertical doping profile to be used in the computation of the doping distribution. The depths and concentrations of the one dimensional vertical profile are obtained from the neutral file which is named in the command. Concentrations must have units of  $cm^{-3}$  and depths must have micron units. The extension .PRO must not be included in the parameter and it must not exceed 20 characters in length. There is a choice of using either a rotated ellipse or a complementary error function to describe the lateral distribution. The lateral standard deviation constant, used with the complementary error function, must have micron units. No doping concentrations are computed outside the range of depths given in this vertical profile.

Windows must be rectangular. Odd shaped windows can be made up as a series of abutting rectangles and must be included in the same string list when the command is used.

It is recommended that no more than three implants share a common window. This is to avoid errors in the calculation of the impurity distribution since the solution assumes non-interacting impurities.

### **Parameters**

FILE

required string

A string which gives the name of the file in which the profile

is stored (the extension .PRO is assumed).

**LATYPE** 

required choice

The type of lateral profile required values are (ROTate, ERFc).

**CONSTANT** 

required real

The positive constant required for the computation of the lateral doping profile. The meaning of the constant is different for each

of the lateral profile types. The constants required are:

(1) rotated ellipse:

 $\alpha$  - parameter describing ellipse (2) complementary error function:  $\sigma_B$  - lateral standard deviation

**DOPTYPE** 

required choice

The type of doping. Values are (Acceptor, Donor).

WINDOW

required stringlist

The list of window names for which this doping is applied.

**ACTION** 

optional choice: initial = ADD

The ACTion, if a window has already been doped is either Add

or Replace. Values are (Add, Replace).

#### **Examples**

PROF FIL=vertic LAT=rotate CON=0.5 DOPT=a WIND=wndw3 prof myfile erfc 3.0 a (w01,w02,wnd4,wnd5) add

### **B.11** RUN - to run the main routine

### **Syntax**

RUN

### Description

Causes the main routine to commence calculating the nodal values of doping density, and to output a doping neutral file.

#### **Parameters**

This command has no parameters.

### **Examples**

RUN

### **B.12** TITLE - to specify a title for the problem

### **Syntax**

TITLE TEXT=<string>

### Description

Specifies the title to be written into the output doping neutral file for identification purposes. It must not exceed 20 characters in length.

### **Parameters**

**TEXT** 

required string

A string value specifying the title in the output doping neutral

file.

### **Examples**

TITLE TEXT=Diode TITLE MOSFET

### B.13 UNIFORM - to specify a uniformly doped volume

#### **Syntax**

UNIForm VOLume=<slist> Acceptor=<real> Donor=<real>

### Description

Specifies the acceptor and donor densities in each volume. To avoid having to type in the same doping values for many volumes, the BACKGROUND command can often be used to advantage.

### **Parameters**

**VOLUME** 

required stringlist

A string value specifying the volume name or names.

**ACCEPTOR** 

required real in  $cm^{-3}$ : always positive

Typical values are in the range  $1 \times 10^{14}$  to  $1 \times 10^{19} cm^{-3}$ .

**DONOR** 

required real in  $cm^{-3}$ : always positive

Typical values are in the range  $1 \times 10^{14}$  to  $1 \times 10^{19} cm^{-3}$ .

### Examples

UNIF VOL=P+SI, A=1.0D18, D=1.0D12 unif n-si, 1.0D12, 1.6D14